



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

July 28, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

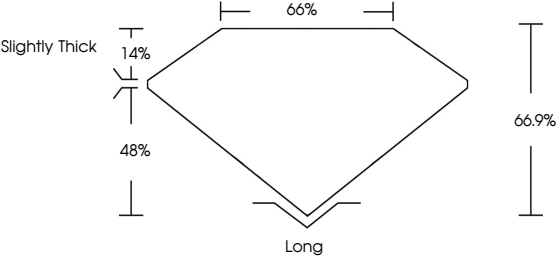
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG821610280

Report verification at [igi.org](#)

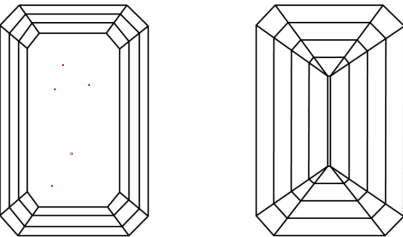
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D	E	F	G	H	I	J	Faint	Very Light	Light
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CLARITY

FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

12.92 X 9.24 X 6.18 MM

7.58 CARATS

F

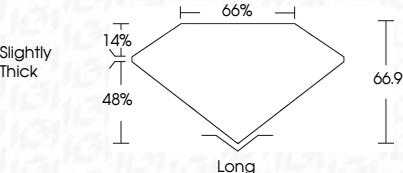
VS 1

EXCELLENT

EXCELLENT

NONE

IGI LG821610280





IGI

July 28, 2026

IGI Report No LG821610280

EMERALD CUT

12.92 X 9.24 X 6.18 MM

7.58 CARATS

F

VS 1

66.9%

66%

Slightly Thick

Long

EXCELLENT

EXCELLENT

NONE

IGI LG821610280

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www.igi.org

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